

DuPont™ Riston® Dry Film Photoresist

RISTON® PATENTED CLEAN DEVELOPER TECHNOLOGY

sludge free

- Improved Yields through Elimination of Developer Sludge
- No Harsh Cleaning Chemicals Result in Fewer Health & Safety Risks
- Reduced Operating Costs

Plugged Nozzle



With Riston® Resists

Sludge Free Developer



With Other Resists



The miracles of science™

sludge free